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The growth mechanism of Pentacene- C_{60} heteroepitaxial films A. AL-MAHBOOB, J.T. SADOWSKI, Y. FUJIKAWA, T. SAKURAI, Institute for Materials Research, Tohoku University — Pentacene (Pn) and fullerene (C_{60}) are of great interest among organic semiconductors as they show highest field-effect hole and electron mobilities respectively. The absorption peak in Pn crystal is located close to maximum of solar visible spectra, making a bipolar $Pn-C_{60}$ diode promising for solar cell application. In order to improve its efficiency to satisfy the requirement for practical application, an in-depth understanding of $Pn-C_{60}$ interface formation is necessary for further optimization. We shall discuss the growth mechanism of $Pn-C_{60}$ heteroepitaxial films on Bi(0001)/Si(111) substrate studied by real time lowenergy electron microscopy and complementary scanning tunneling microscopy. A competitive growth between a thin-film phase of Pn having standing-up orientation and a phase with laying-down orientation has been observed. The growth of layingdown phase is suppressed gradually with increasing film thickness. The nucleation of this phase is also suppressed with increasing temperature and the standing up phase without co-presence of laying down phase is achievable at ~ 75 ° C.

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